

# Too Hot to Test? For Leading-edge SoC and Heterogenous Integrated IC Stack

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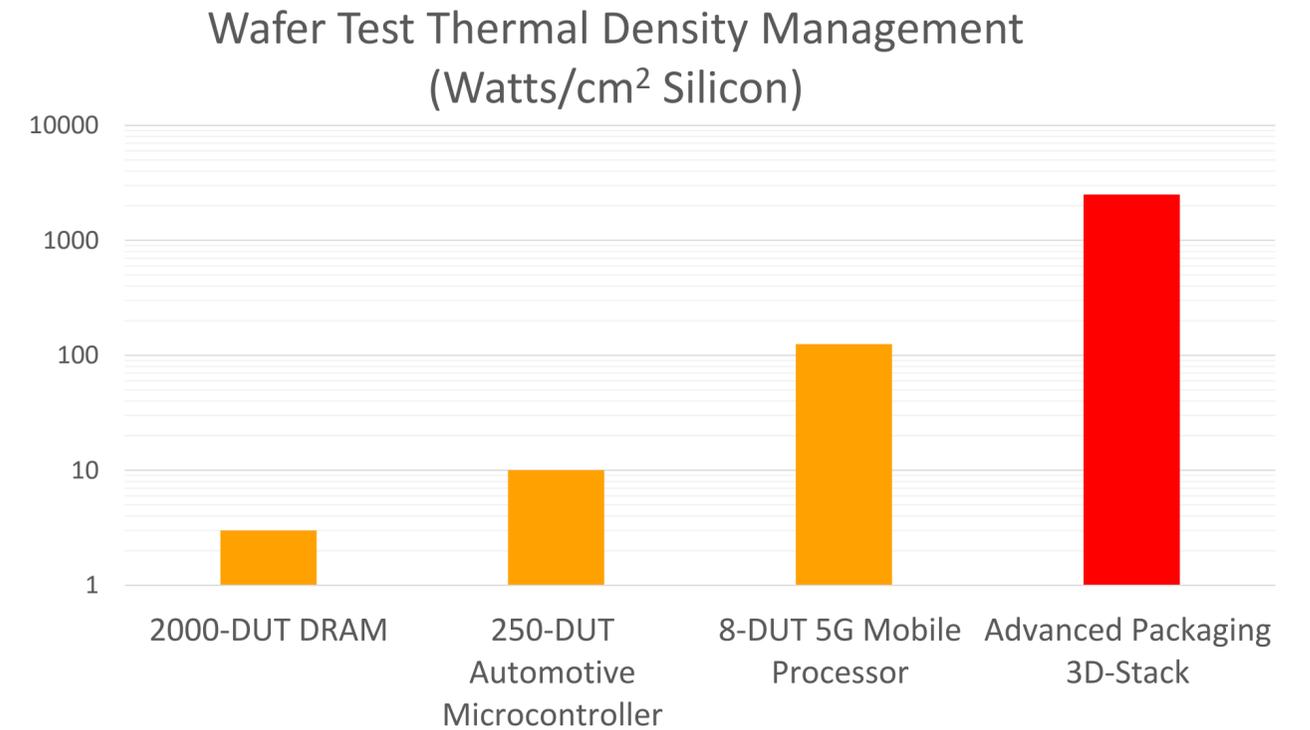
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# Wafer Test Trends – Too Hot To Test?

- Testing of high power IC's (i.e. AI/Processors ) + 1TD DRAM is approaching an inflection point
- High power density of DUT's need better thermal chuck to dissipate the peak power
- Standard wafer chucks are not able to sense temp increase and to dissipate the applied energy, resulting in
  - device damage
  - burned probes
  - inaccurate test results
- Heterogenous integration will further increase power densities by >10X
  - processor + HBM (8 – 16 die) stacked on a base wafer
- Active temperature control solutions are required
  - Low Thermal Resistance
  - MultiSense Temp Control – Liquid Cooling
- ATT's Low Thermal Resistance (LTR) chuck technology addresses these challenges





# What is a Thermal Chuck?

## Air Cooled



-40C to +200C

-60C to +200C

## Modular Base Chuck System



Universal chuck and controller

2 independent cooling circuits

+20C to +200C without chiller

## Liquid Cooled



-20C to +200C

-40C to +200C

-60C to +200C



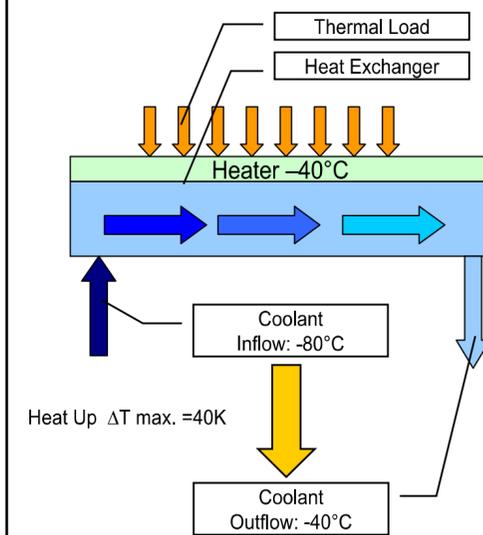


# High Power Testing – Why Liquid Cool?

## Air-Cooled

### Cooling with air

What power do we need to test at -40°C



Maximum Airflow: 320l/min

$$\rho_{AIR} = 0,00129kg / dm^3$$

$$c_{AIR} = 1,0KJ / (KgK)$$

$$m_{AIR} = 410g$$

$$\Delta T_{max} = 40K$$

$$P_{max} = 275W @ -40^\circ C$$

$$Q = \frac{c \cdot m \cdot \Delta T}{t}$$

$$\Delta T = \frac{Q_{Last} \cdot t}{c \cdot m}$$

As the idle power @-40°C is about 180W there are left about **100W** to take away heat generated by testing.

Max. Cooling Capacity is low at 275W

Effective Cooling Capacity is low at 100W

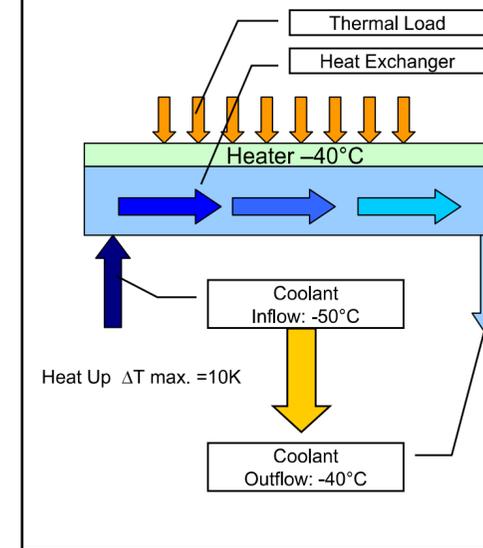
ΔT high – impact on temp. uniformity

High air-flow@high pressure

## Liquid-Cooled

### Cooling with liquid

What power do we need to test at -40°C



Coolant Flow: 10l/min

$$\rho_{Zr130} = 1,8kg / dm^3$$

$$c_{Zr130} = 1,1KJ / (KgK)$$

$$m_{Zr130} = 18000g$$

$$\Delta T_{max} = 10K$$

$$P_{max} = 3300W$$

For 200W and 600W heat load applied by testing following ratios are calculated

$$P_{load} = 200W$$

$$c_{Zr130} = 1,1KJ / (KgK)$$

$$m_{Zr130} = 18000g$$

$$\Delta T = \frac{Q_{Last} \cdot t}{c \cdot m} = 1,15K$$

$$P_{load} = 600W$$

$$c_{Zr130} = 1,1KJ / (KgK)$$

$$m_{Zr130} = 18000g$$

$$\Delta T = \frac{Q_{Last} \cdot t}{c \cdot m} = 2,35K$$

Max. Cooling Capacity is high at >3000W

ΔT low – low impact on temp. uniformity

Reasonable cooling fluid consumption

Wider temp range might require other fluids

Liquid cooled systems are the tools of choice due to the high cooling power and better temp. uniformity!



# Active Temperature Control – MultiSense

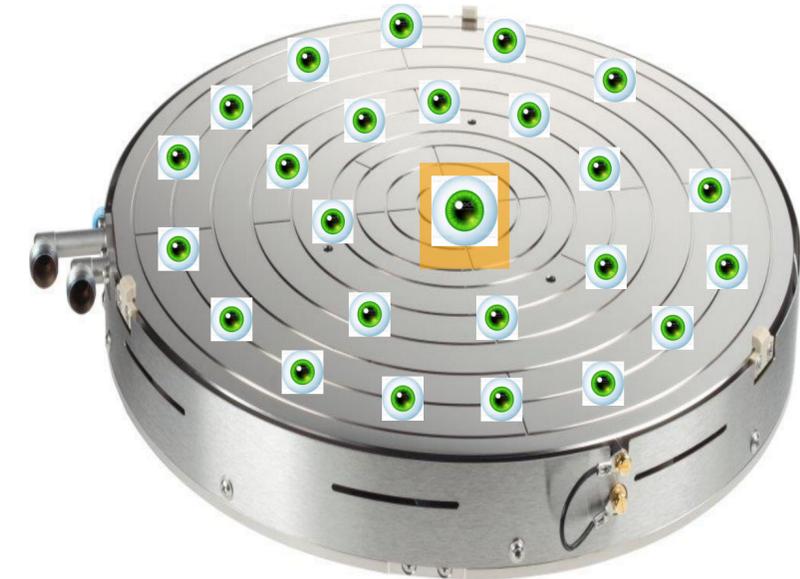
Full Wafer Contact



100x100mm



20x20mm



- Full Wafer Contact: Uniformly distributed thermal load - one control sensor is sufficient
- Smaller Contact Areas: Require multiple control sensors to detect temp changes
- Number of built-in sensors is limited due to chuck complexity – total of 9 control sensors
- MultiSense AddOn sensors is scalable, currently up to 21 sensors
- Requires advanced temp control algorithms





# MultiSense vs. No MultiSense

+70°C, 200W, 21x22mm contact area, 2 min test time, liquid cooled

With MultiSense



Limited temp increase – 74.1°C

+/- 1°C after 28 sec

Power dissipated after 33 sec

Test Set-Up

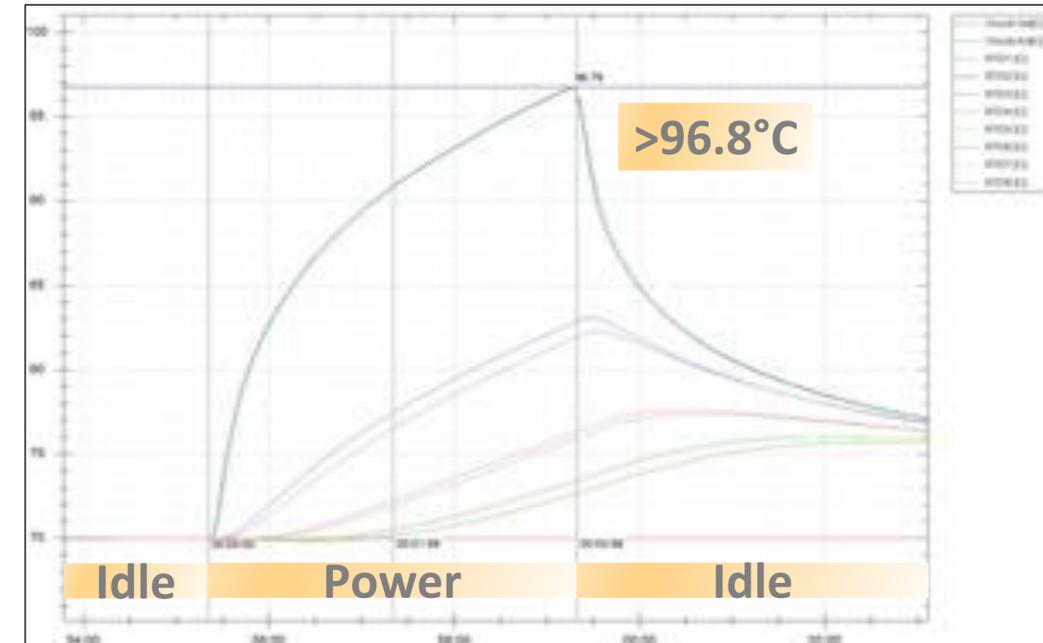


Resistor 21x22

200W max

Test Time: 2 min

Without MultiSense



Uncontrolled temp rise to >96°C

No temp change detection

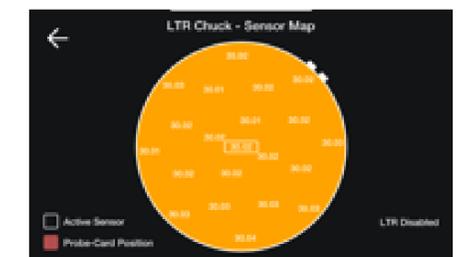
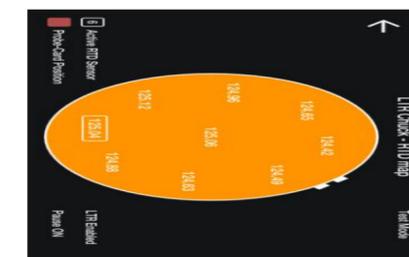
No Active Temp Control





# ATT's Low Thermal Resistance (LTR) Chuck Technology

- Developed for High Power (HP) and High Accuracy (HA) Applications
- AI devices, GPU's, CPU's, Stacked Memories, Heterogenous integrated devices
- Low Thermal Resistance chuck design w/ MultiSense Active Temp Control
- Scalable number of temp control sensors (e.g. 9 or 21 sensors)
- Scalable cooling power options, upgradeable as needed (600W to >20KW)





# Application Examples

Full Wafer Contact  
 DRAM, Flash, HBM



Contact Area: Large  
 Parallelism: High

Power/Die: Low  
 Density: Low (3W/cm<sup>2</sup>)

Heat transfer: up to 2000W  
 Temp. Range: -40°C to +125°C

100x100mm  
 E.g. Microcontroller



Contact Area: Medium  
 Parallelism: Medium/Low

Heat transfer: up to 1000W  
 Temp. Range: -40°C to +125°C

Power/Die: Medium/High  
 Density: Medium (10W/cm<sup>2</sup>)

20x20mm  
 E.g. 5G or GPU devices

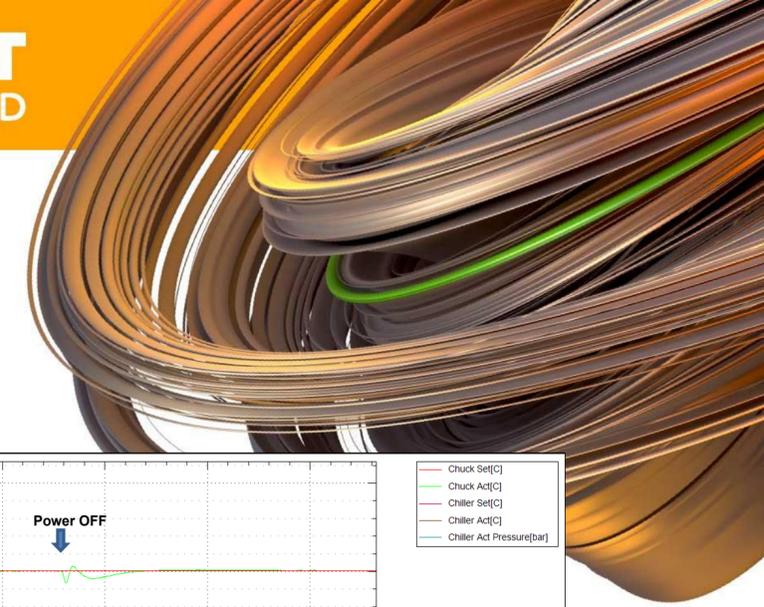


Contact Area: Small  
 Parallelism: Low

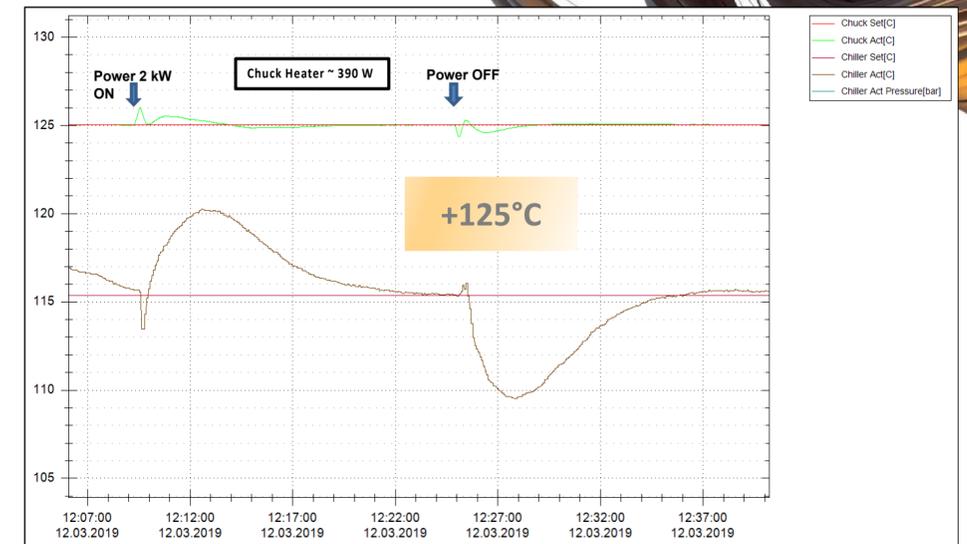
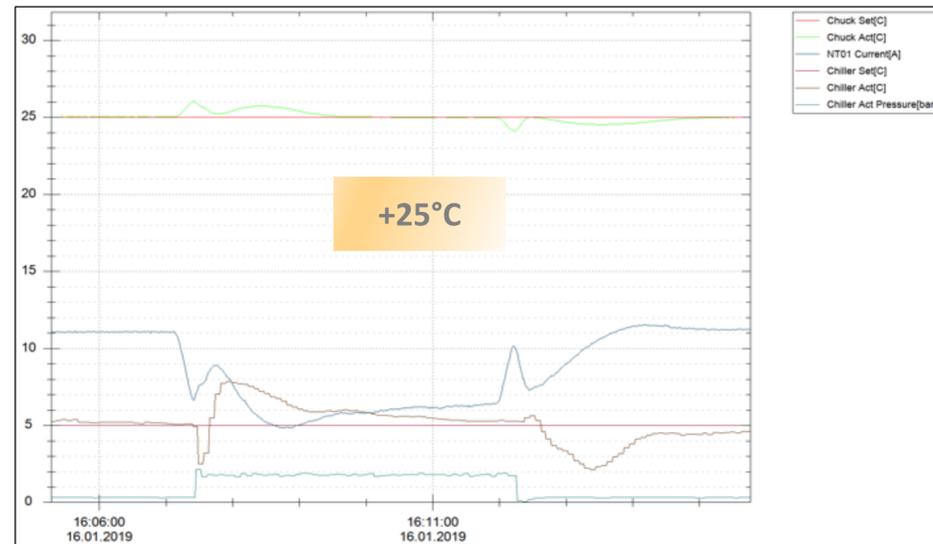
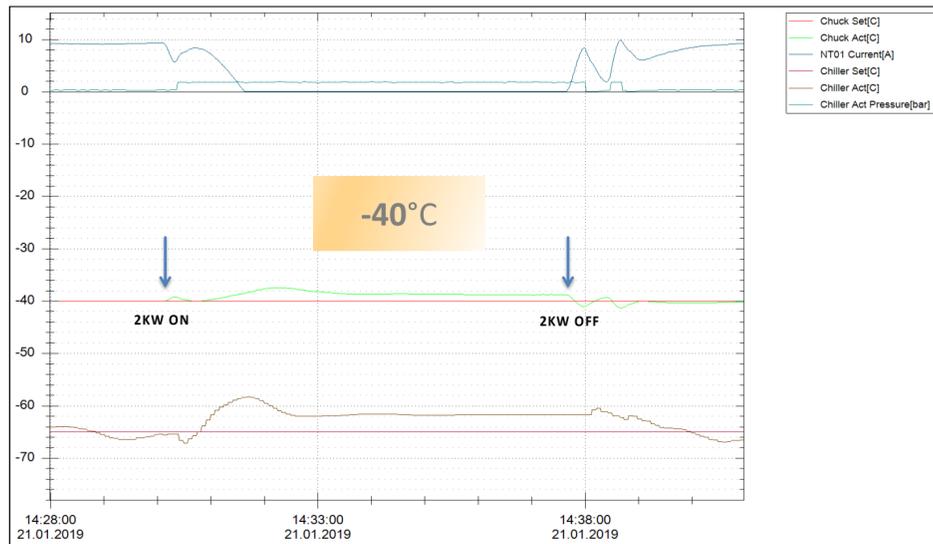
Power/Die: High  
 Power Density: High (125W/cm<sup>2</sup>)

Heat transfer: up to 500W  
 Temp. Range: -40°C to +125°C





# Customer Case Study – Full Wafer Contact, 2000W

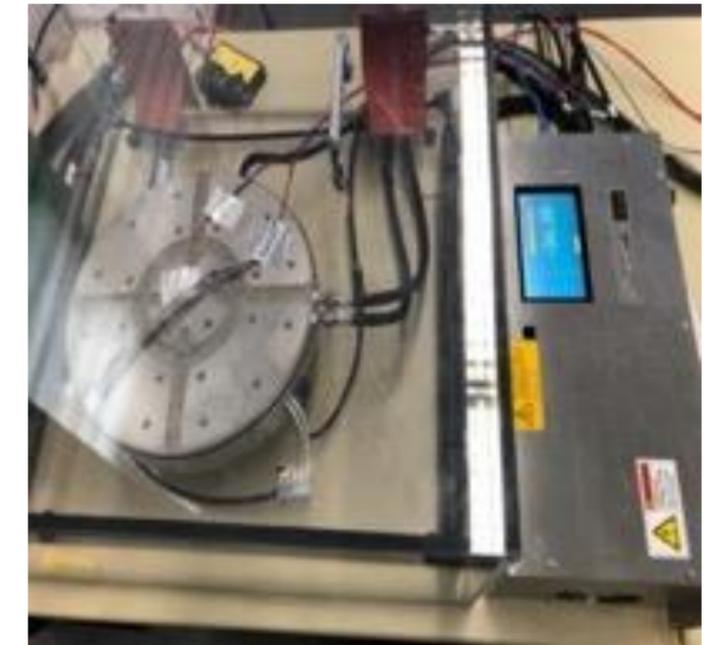


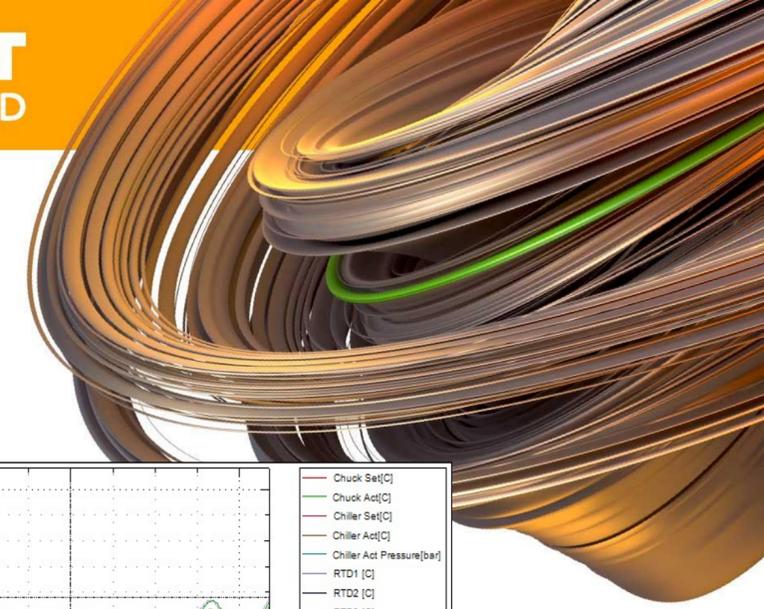
Full Wafer Contact – High Bandwidth Memory Testing

Applied power of 2000 Watts, uniformly distributed across the chuck

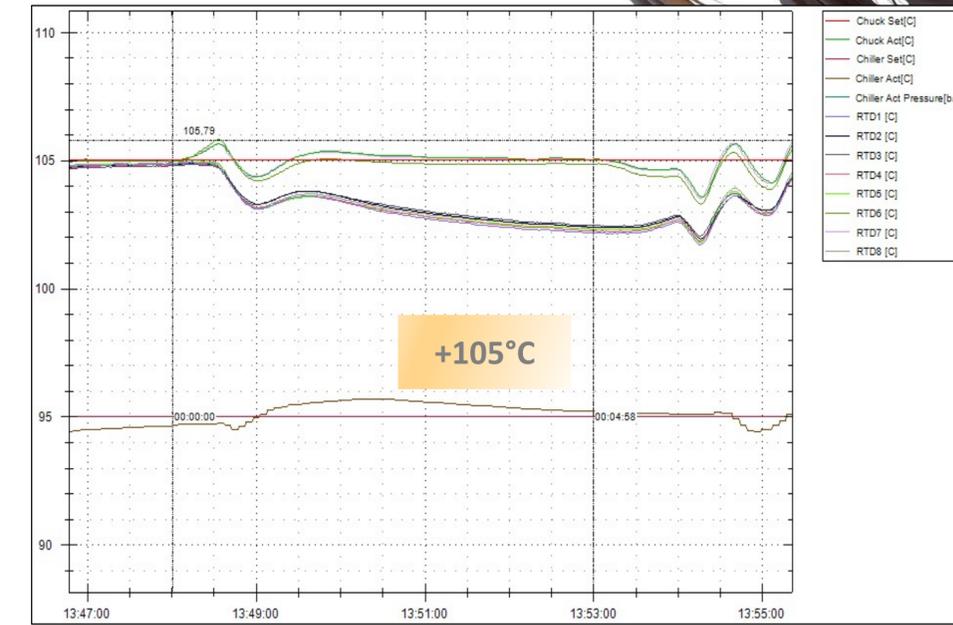
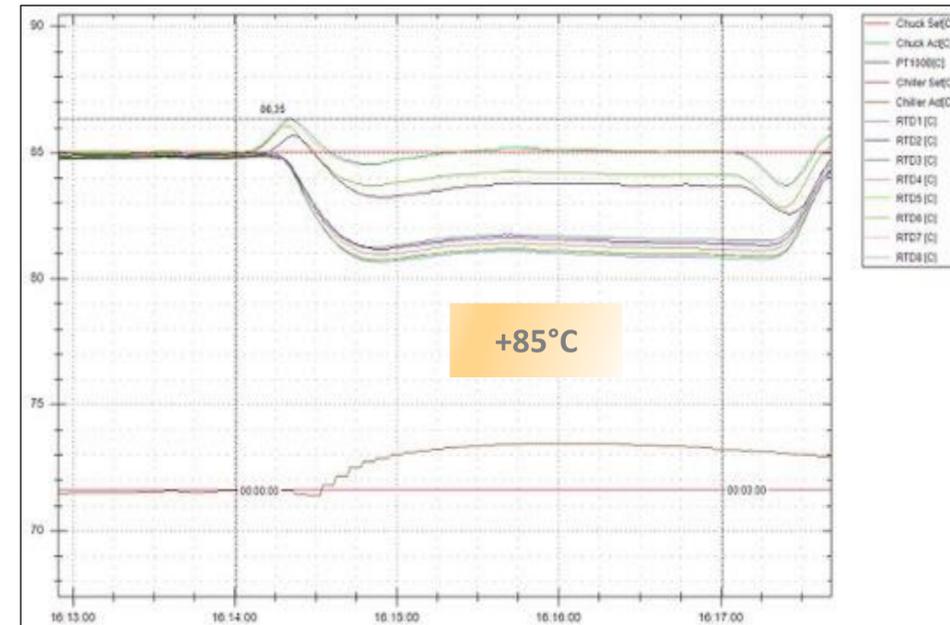
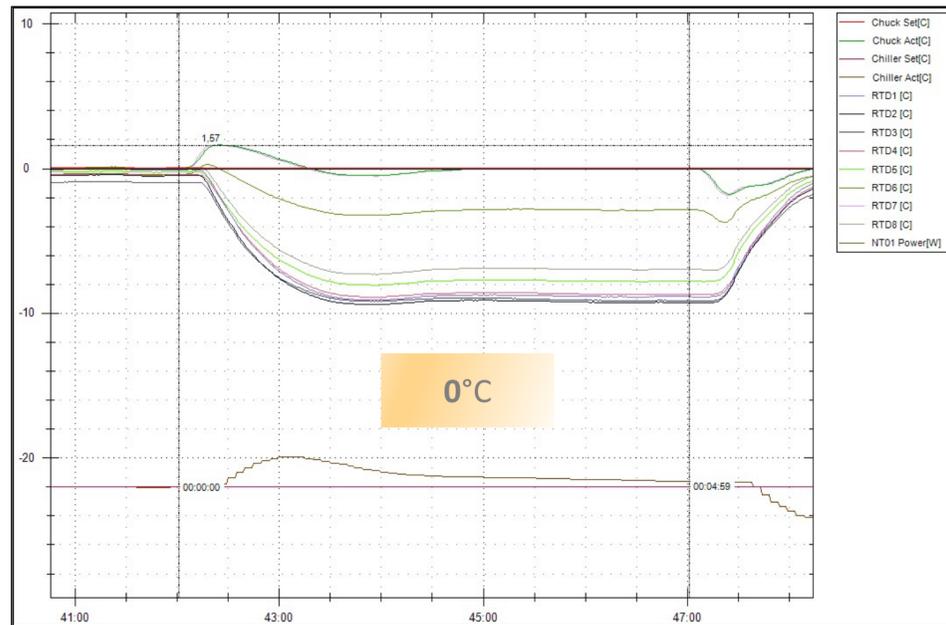
Liquid Chiller, -40°C, +25°C and +125°C

Chuck system is able to dissipate 2000W at all three temperatures





# Customer Study – 100x100mm, 400W



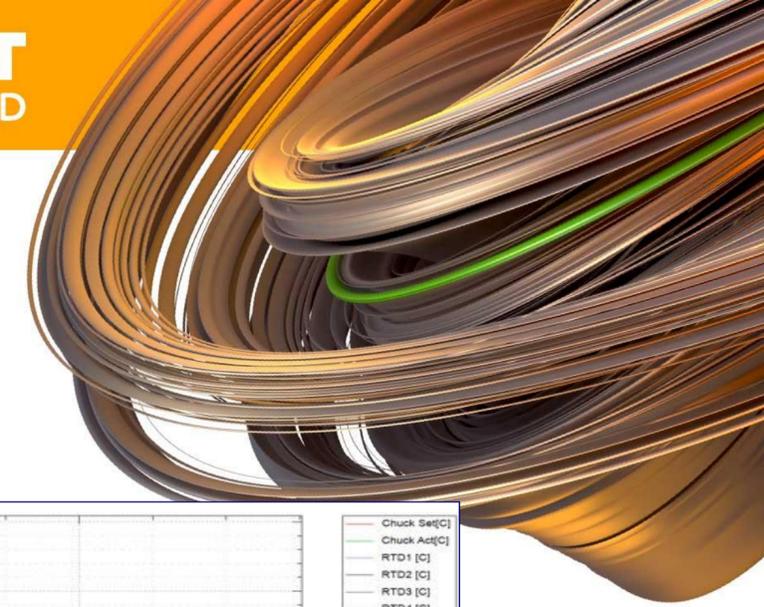
100x100mm contact area – Automotive microcontroller

Applied power of 400 Watts

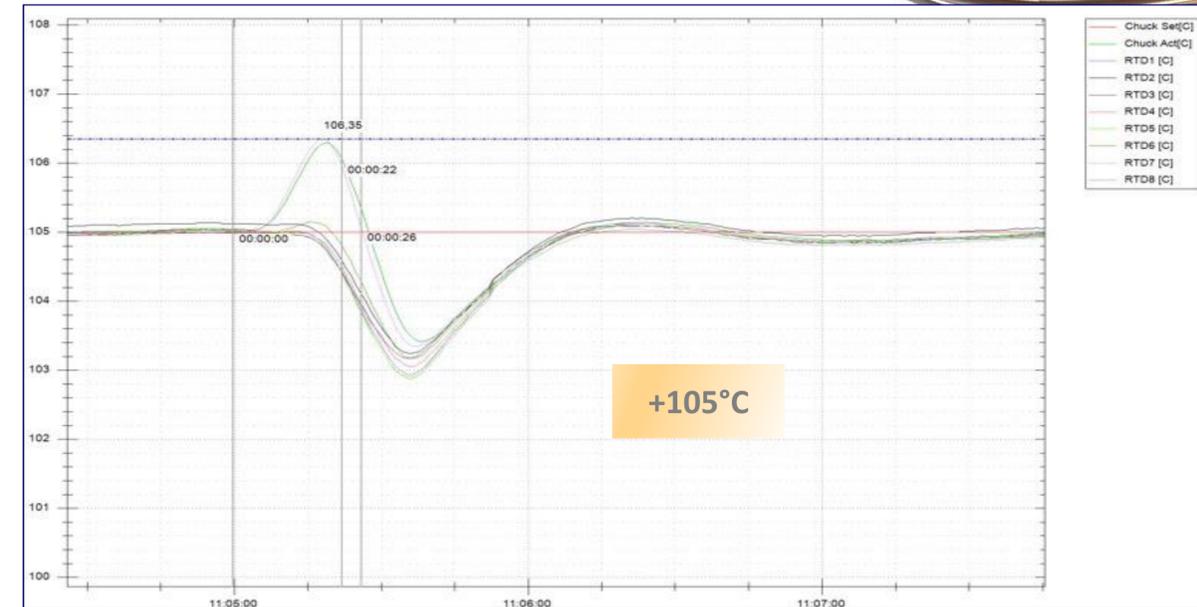
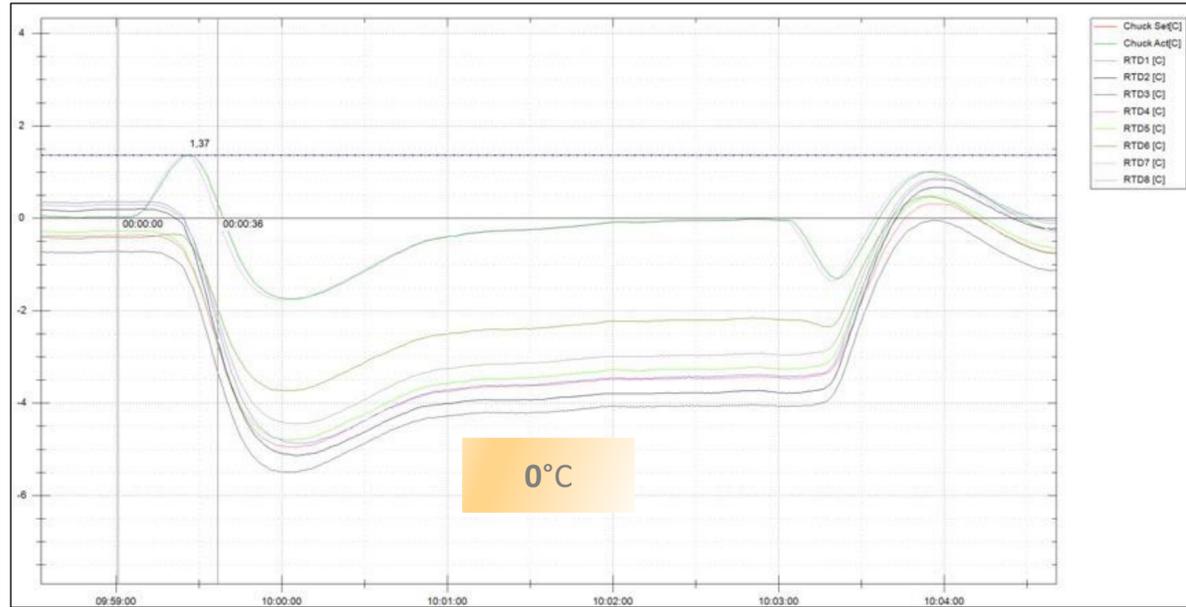
Liquid Chiller, 0°C, +85°C and +105°C

Chuck system is able to dissipate 400W within a +/- 2°C temperature range





# Customer Study – 21x20mm – 160W



21x20mm contact area – 5G Device

Applied power of 160 Watts

Liquid Chiller, 0°C and +105°C

Chuck system is able to dissipate 400W within a +/- 2°C temperature range



# Summary

- Increasing thermal challenges to test leading-edge SoC, full-wafer memory, and heterogenous integrated device require Liquid Cooled wafer chuck systems for high power dissipation
- Customer case study showed ATT's Low Thermal Resistance (LTR) chuck is doable for
  - Full Wafer Contact up to 2KW
  - 100x100mm up to 400W – higher power possible with stronger chillers
  - 21x20mm up to 160W – higher power possible with stronger chillers
- Wafer test requirements are changing dynamically – Power densities, Parallelism, IC complexity
- ATT is working on new chuck concepts addressing future requirements – Please contact us for more details



Thank You

